

LOW COST FEATURE TO INDICATE PACKAGE ORIENTATION

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FIELD OF THE INVENTION

This invention relates to the field of integrated circuit packaging, more particularly to
5 methods of indicating the orientation of a semiconductor package.

BACKGROUND OF THE INVENTION

Integrated circuit packages use a variety of means to indicate the orientation of the
package. Integrated circuits encapsulated in plastic often have an indentation on the surface of
the package to indicate the location of pin one of the package. Other packages used a painted
10 dot, or a chamfered corner to indicate the proper orientation. While the indentation in a plastic
package is essentially cost free, each of the other means of marking the orientation of the
package results in added package cost. The alternate methods also have other shortcomings. For
example, marking the package lid does not provide a reference during the fabrication of the
package. Likewise, a chamfer on a package corner may be difficult to see under certain
15 conditions. While these shortcomings are of no importance for many integrated circuits, the
assembly of which is completely automated, improper keying during hand assembly operations
leads to expensive waste in the manufacture of some integrated circuits, most notably
microelectromechanical systems (MEMS). Furthermore, some electro-optic MEMS devices
typically use a glass plate for the package lid. Markings on the glass lid can cause unwanted
20 reflections that degrade the performance of the device. Additionally, markings on the glass are
not available to use to orient the package during assembly.

SUMMARY OF THE INVENTION

Objects and advantages will be obvious, and will in part appear hereinafter and will be accomplished by the present invention which provides a method and system for a low cost feature to indicate package orientation. One embodiment of the invention provides a substrate for a device package. The package substrate comprising: a lower portion of a package; an intermediate metalization layer on a top surface of the lower portion; an upper portion of the package on the top surface of the lower portion, a corner portion of the intermediate metalization layer remaining visible beyond the extent of the upper portion for indicating an orientation of the substrate.

According to another embodiment, a method of forming a device package is provided. The method comprising: providing a lower portion of a package; providing an intermediate metalization layer on a top surface of the lower portion; providing an upper portion of the package on the top surface of the lower portion, a corner portion of the intermediate metalization layer remaining visible beyond the extent of the upper portion for indicating an orientation of the substrate.

BRIEF DESCRIPTION OF THE DRAWINGS

For a more complete understanding of the present invention, and the advantages thereof, reference is now made to the following descriptions taken in conjunction with the accompanying drawings, in which:

5 FIGURE 1 is an exploded perspective view of a package according to one embodiment of the present invention showing the layers used to form the package substrate.

FIGURE 2 is an exploded perspective view of sheets of material laminated to form the package of Figure 1.

10 FIGURE 3 is an exploded perspective view of the sheets of material of Figure 2 with additional voids created to provide mechanical access to a reference plane.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

A new integrated circuit package and method of forming a package has been developed that provides excellent visibility to the orientation of the package substrate throughout all stages of the device assembly process, and over a wide range of ambient light conditions. The package
5 uses an existing metalization layer to designate a reference corner of the package. Since an existing layer is used, virtually no additional cost is incurred to use the new orientation indicator.

Figure 1 is an exploded perspective view of a package according to one embodiment of the present invention showing the layers used to form the package substrate. In Figure 1, a lower portion 102 of the package includes an intermediate metalization layer patterned on the surface
10 of the lower portion. This metalization is used to connect the device 104 being packaged with circuitry outside the package.

The lower portion 102 of the package is formed through known methods. The lower portion 102 may be laminated from several layers with metalization between the layers. Connections between the layers of metalization complete connections between the bond pads
15 106 on the interior of the package and package leads, not shown, on the bottom of the package. Alternatively, the metalization is preformed to extend through the lower portion 102 of the package and the material forming the lower portion of the package is formed around the metalization. The lower portion 102 of the package typically is ceramic, but may be polyamide, plastic, or other materials.

20 An upper portion 108 of the package is supported by the lower portion of the package and sandwiches the intermediate layer. At least one corner of the upper layer 108 is cut back to expose a region 110 of the intermediate metalization layer. This region is highly visible since it is reflective and located outside of the package cavity. The metalization region 110 may also be

plated or tinned to increase its visibility. The metalization region 110 typically is electrically isolated from the remainder of the metalization conductors used to connect the packaged device 104 with the external circuitry.

Unlike orientation designators located on the top of a package, the metalization region 110 is visible before the package has been completed. This is useful when manufacturing steps rely on human intervention or assistance.

After the device 104 is installed on the package substrate, it is sealed in the package by a lid 112. The lid likely is a glass plate, but may be a metal, ceramic, or plastic cover or formed from another material. The disclosed package is useful for packaging many types of integrated circuits, but is most useful for packaging electro-optical devices such a micromirror array. Electro-optical devices use a transparent lid to allow light to enter and exit the package. Traditional methods of indicating the orientation of the package, such as an ink spot in one corner of the package, may create unwanted reflections or other aberrations in the window.

Figure 2 is an exploded perspective view of sheets of material laminated to form the package of Figure 1. Figure 2 illustrates how the void in the upper portion of the package is formed. A first sheet 202 of substrate material is formed. The first sheet includes the lower portion and the intermediate metalization layer for several package substrates, and any other necessary interconnection layers. A second sheet 204 of substrate material is formed to include voids 206 to form the package cavity and expose a region of the metalization layer. Like the first sheet, the second sheet will form the upper portion of several package substrates.

The first 202 and second 204 sheets typically are an unfired ceramic material. After the sheets have been assembled, they are fired. The fired sheet is then separated into individual

substrates, typically by scribing and breaking the fired sheet. The edges of the individual substrates are then ground.

In addition to exposing a portion of the intermediate metalization layer, the void in the upper portion of the package may be used to physically position and align the packaged device.

5 This is especially useful with electro-optical devices such as micromirror array. Micromirror arrays typically require precise alignment with external optical components. Typical integrated circuits do not require similar alignment since the position of the actual device is not important and may vary from package to package so long as the location of the package terminals remains constant.

10 One method of aligning the micromirror array to external optical components uses predefined points on the package substrate and on the edge of the package substrate to define a reference plane. When the package is assembled, the micromirror array is placed at a predetermined point offset relative to the reference plane and the package edges. The system in which the packaged micromirror array is later installed holds the micromirror package by these same regions so that the reference coordinates are consistently used. Early devices used the top surface of the package, or the top surface of the glass window to define a reference plane. The use of the top surface introduced variance in the location of the micromirror since the offset between the plane on which the micromirror was mounted and the top of the package was not well controlled.

20 Modern packages provide voids in the upper portion of the package to allow access to the top surface of the lower portion of the package substrate. Since the micromirror is attached directly to this top surface, variances in the upper portion of the package do not affect the accuracy of the micromirror alignment. The void created to allow visual access to the

intermediate metalization layer also provides mechanical access to this reference plane. Figure 3 shows the sheets of substrate material from Figure 2 with voids created to provide three points of mechanical access to the reference plane of each device.

Thus, although there has been disclosed to this point a particular embodiment for a low cost feature to indicate package orientation and method therefore, it is not intended that such specific references be considered limitations upon the scope of this invention except insofar as set forth in the following claims. Furthermore, having described the invention in connection with certain specific embodiments thereof, it is to be understood that further modifications may now suggest themselves to those skilled in the art. It is intended to cover all such modifications as fall within the scope of the appended claims. In the following claims, only elements denoted by the words "means for" are intended to be interpreted as means plus function claims under 35 U.S.C. § 112, paragraph six.